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	Class	Subclass
ISSUE CLASSIFICATION		

~~PATENT NUMBER~~

U.S. **UTILITY** Patent Application

O.I.P.E. <i>RT</i> SCANNED <i>2005</i> Q.A. <i>11/11</i>	PATENT DATE
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APPLICATION NO. 09/634209	CONT/PRIOR	CLASS 257 43	SUBCLASS 118	ART UNIT 2814	EXAMINER H. J. P. H. J.
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Stephen Park
Christian Zistel

Depth of focus (DOF) for trench-first-via-last (TFVL) damascene processing with hard mask and low viscosity photoresist

PTO-2040
12/89

ISSUING CLASSIFICATION									
ORIGINAL		CROSS REFERENCE(S)							
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						
INTERNATIONAL CLASSIFICATION									

Continued on Issue Slip Inside File Jacket

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed. <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____ _____ _____	_____ (Assistant Examiner) (Date)		NOTICE OF ALLOWANCE MAILED	
	_____ (Primary Examiner) (Date)		ISSUE FEE	
<input type="checkbox"/> The terminal ____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)		ISSUE BATCH NUMBER _____	
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